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REACTIONS OF DIFLUOROSILYLENE WITH CYCLIC ALKENES: CYCLOPENTADIENE AND CYCLOHEPTATRIENE

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Summary

The reactions of difluorosilylene with cyclopentadiene and cycloheptatriene were studied both in the gas phase and by the cocondensation method. Several new organosilicon compounds were synthesized and their structures characterized. In the cycloheptatriene reaction the comparison between the results from the gas phase and cocondensation experiments provides the first solid evidence which makes it possible to differentiate between the silirane mechanism and the \cdot SiF₂SiF₂ \cdot diradical mechanism in the "addition reactions" of difluorosilylene.

Introduction

The reactions of difluorosilylene with cyclic olefins such as cyclopentene and cyclohexadiene [1] have been reported previously. The results were consistent with the mechanism involving the \cdot SiF₂SiF₂ \cdot diradical intermediate [2,3]; however, the products were equally well explained by the mechanism involving the initial formation of a silirane intermediate [4].

Previous studies on the insertion reactions of difluorosilylene with fluorine-substituted ethylenes [5] have confirmed that monomeric SiF₂ attacks the carbon-carbon double bond, the adduct then rearranges to an insertion product such as $CH_2=CHSiF_3$, and the $\cdot(SiF_2)_n \cdot (n = 2, 3)$ diradicals are responsible for the formation of $CH_2=CH(SiF_2)_n F(n = 2, 3)$ in the cocondensation reactions at $-196^{\circ}C$.

The strategy used to prove the involvement of the \cdot SiF₂SiF₂ · diradical mechanism is as follows: the selection of one product which can not possibly be formed by dimerization of the silirane intermediate, e.g., CH₂=CHSiF₂SiF₃ (in the case of the CH₂=CHF/SiF₂ reaction), only proves that it cannot be formed by sequential insertion of SiF₂ either [5]. In the case of dimethylsilylene, Sakurai et al. have reported the differentiation between the silylene and disilene mechanisms [6].

The attempt to clarify the reaction mechanism in the addition reactions, however, encounters some difficulties. For example, the addition reaction of diffuorosilylene with propene under cocondensation conditions yielded the disilacyclobutane 1, disilacyclohexane 2, and disilane 3 as products [3,7].



Both the silirane mechanism and the diradical \cdot SiF₂SiF₂ · mechanism have been proposed to account for these products [3,7]. In this case compound 1 can not possibly be formed by dimerization of the silirane intermediate. However, the formation of 1 has been interpreted by a process of further insertion of SiF₂ into the initially formed silirane intermediate [4,8]. Although the insertion of SiF₂ into difluorosilirane has not been proved experimentally, such reactions are believed to occur in the case of dimethylsilylene [9].

In this paper we report our study on the reactions of difluorosilylene with cyclopentadiene and cycloheptatriene, the results show direct evidence for the coexistence of the \cdot SiF₂SiF₂ · diradical mechanism with the silirane mechanism in the cocondensation reactions.

Results and discussion

Reaction with cyclopentadiene. The gas phase reaction of difluorosilylene with freshly prepared cyclopentadiene was carried out by the same experimental procedures as previously described [11]. Under these experimental conditions no polymerization of SiF_2 was allowed so the reactions must be reactions of monomeric SiF_2 [10].

The major product of the gas phase reaction of SiF_2 with C_5H_6 was a white polymeric material which formed a film that coated the wall of the reaction bulb. The minor volatile products, which accounted for only approximately 15% total yield, contained mainly the components **4a**, **4b**, **5a**, **5b** and **6**.



Using different separation conditions, it was possible to obtain samples of the mixtures of 4a/4b + 5a/5b + 6, 4a/4b + 5a/5b and 4a/4b (see Experimental). The mass spectral data suggested that there were at least three types of molecular formulae involved, $C_5H_7SiF_3$ (m/e 152), $C_5H_5SiF_3$ (m/e 150) and $C_5H_6SiF_2$ (m/e 132). The mass spectral data and relative yields (determined by NMR) are summarized in Table 1.

The proton noise decoupled ¹⁹F NMR spectra of 4a, 4b, 5a and 5b all consisted of a sharp singlet in the typical resonance region for SiF₃ (130–145 ppm). Compounds 4a/4b and 5a/5b are the most likely structures for the molecular formulae C₅H₇SiF₃ and C₅H₅SiF₃, respectively. The ¹⁹F NMR spectrum of 6 was complicated. When the proton noise was decoupled, the spectrum showed two doublets (with J 120 Hz) centered at 116.66 and 147.96 ppm, respectively. These are characteristic features of

Fragment	m/e	Relative intensity (%)						
		4a/4b + 5a/5b + 6 "	4a/4b + 5a/5b "	4a/4b	7	7+8°	7+9 ^d	10 + 11 ^e
SiF ⁺	47	40	62	35				18
C ₅ H ₅ ⁺	65	11	6	15	3	13	5	7
$C_5 H_6^+ (SiF_2^+)$	66	98	10	18	13	100	85	12
$C_5H_7^+(SiF_2H^+)$	67	100	100	100	2	23	60	45
SiF ₃ ⁺	85	23	36	46			23	2
C ₅ H ₆ SiF ⁺	113				13	10	15	6
$C_5H_6SiF_2^+, Si_2F_4^+$	132	85			9	95	45	85
C,H,SiF ₃ ⁺	150	8	17					
$C_{5}H_{6}SiF_{3}^{+}(Si_{2}F_{5}^{+})$	151					90	80	93
$C_5H_7SiF_3^+$	152	53	48	60				
$C_{5}H_{6}Si_{2}F_{3}^{+}$	179					3	5	4
$C_5H_6Si_2F_4^+$	198				100	97	90	
$C_5H_7Si_2F_5^+$	218						45	
$C_{10}H_{12}Si_2F_4^+$			264					100

MASS SPECTRAL DATA OF THE PRODUCTS FROM THE REACTION OF DIFLUOROSILY-LENE WITH CYCLOPENTADIENE

 $a^{a} 4a/4b/5a/5b:6 = 3:9:1$. $b^{b} 4a/4b:5a/5b = 11/4$. $c^{c} 7:8 = 10:3$. $d^{c} 7:9 = 4:1$. $e^{c} 10:11 = 8:1$.

a bridge-head SiF₂ group in bicyclic molecules [11]. One interesting spectral feature worth mentioning is the unusually large four-bond coupling constant between F^A and H^B (*J*(F-H) 40 Hz) due to a double W shape relationship between the two nuclei. The NMR spectral parameters are summarized in Table 2.



The cocondensation reaction of difluorosilylene with cyclopentadiene resulted in a yellowish brown polymer (yield 48%) and a number of volatile products (yield 18%). The volatile products were separated into three fractions according to the volatility: (i) a fraction volatile at -50° C collected at -78° C, (ii) a fraction volatile at -15° C collected at -35° C and (iii) a fraction volatile at room temperature which was collected at 0° C.

Fraction (i) contained the same products as those obtained in the gas phase reaction. Fraction (ii) contained three compounds 7, 8, and 9 in a relative abundance ratio 20/5/1.

Compound 7, a colorless crystalline material, could be purified by low temperature filtration followed by sublimation under vacuum. Both the mass spectrum and elemental analysis indicated the molecular formula $C_5H_6Si_2F_4$ (Found: C, 30.40, H, 3.14; calcd.: C, 30.33, H, 3.03%.) The proton noise decoupled ¹⁹F NMR spectrum showed two sets of doublet of doublets centered at 139.49 and 147.38 ppm,

NMR PARAMETERS OF PRODUCTS FROM THE REACTION OF DIFLUOROSILYLENE WITH CYCLOPENTADIENE

Compound	Che	mical shift (8,	Coupling constant (Hz)				
		¹ H	¹⁹ F		¹³ C	²⁹ Si	
4a/4b	sp ²	6.2(br)	140.70	(s)			····
	sp ³	2.2 ~ 2.8(br)	141.16	(s)			
5a/5b	sp^2	6.2 ~ 6.4(br)	138.06	(s)			
	sp ³	2.5(br)	139.86	(s)			
6	sp ²	5.4(br)	116.66	(AX)			$^{2}J(F-F)$ 120
	sp ³	2.0(br) 1.5(br)	147.96	()			⁴ J(F-H) 40 (W shape)
7	sp ²	6.15(br)	139.49	(d,d)	<i>sp</i> ² 131.12(s)	29.11 (d,d,d,d)	$^{2}J(F-F)$ 30.0
	sp^3	CH 2.1(br)	147.33	(d,d)	sp ³ 31.85(c)		$^{3}J(F-F)$ 15.0
	sp ³	CH ₂ 2.6(br)			31.88		$^{1}J(Si-F)$ 352.4, 371.5 $^{2}J(Si-F)$ 49.10, 34.25
8	sp ²	6.3(c)	SiF ₂	120.07(c)	sp^2 127.09(s)		$^{2}J(H-F)$ 60.0
-	sp^3	2.7(m)	HSiF,	137.54(c)	131.37(s)		$^{3}J(H-F)$ 10.0
	SiH	4.6(t,t)	-		sp^3 28.0(c)		
9	sp^2	6.15(br)	SiF ₃	141.6(d,d)	sp ² 128.37(s)		$^{2}J(H-F)$ 68.0
	sp^3	2.6(m)	SiF,	144.0 (A.B. I)	128.49(s)		$^{2}J(F-F) 8.0$
	•	$2.8 \sim 3.0(m)$	-	144.6 (AB,d)	sp ³ 22.40(c)	I.	
	SiH	4.73(t)			14.12(s)		
10/11	sp ² sp ³	5.6 ~ 6.0(br) 1.4 ~ 1.9(br) 2.1 ~ 2.8(br)	10	142.96 145.42 (AA'BB')			
		2.9 ~ 3.4(br)	11	136.49(t) 130.53(t)			

respectively. This is a typical AA'XX' pattern of the SiF₂SiF₂ unit in the bicyclic structure [1,11]. Further evidence came from the ²⁹Si NMR spectrum which showed a doublet (${}^{1}J(Si-F^{A(X)})$ 371.5 Hz) of doublets (${}^{1}J(Si-F^{X(A)})$ 352.4 Hz) of doublets (${}^{2}J(Si-F'^{X(A)})$ 49.10 Hz) of doublet (${}^{2}J(Si-F'^{(AX)})$ 34.25 Hz), with F^A and F^X arbitrarily assigned to the geminal fluorines.



Compound 8 was purified by prolonged pumping off this fraction through a trap at -30° C and collected at -196° C. It was found to have the same molecular formula, $C_5H_6Si_2F_4$, as 7. Both its ¹H and ¹⁹F spectra showed the existence of the moiety SiF₂SiF₂H. The typically large ¹J(F-H) (60 Hz) makes the assignment easier. It was further found from the peak intensity that four unsaturated protons were

involved in compound 8, the only structure that fits these spectral features is shown below:

The ¹³C NMR spectrum showed in addition to the two types of sp^2 carbons a saturated carbon at 28.0 ppm which showed multiplicity as a result of being coupled with the neighboring fluorines. This is a further piece of evidence for the structure assignment of compound 8.

Compound 9 could not be separated completely from compound 7. However, the highest mass in the mass spectrum (m/e 218) suggested that 9 had the molecular formula $C_5H_7Si_2F_5$.

Both the ¹H and ¹⁹F NMR spectra of compound **9** showed typical geminal F-H coupling (68 Hz) which suggested the existence of the SiF₂H moiety. The proton decoupled ¹⁹F NMR spectrum showed two resonances centered at 141.6 and 144.3 ppm with an intensity ratio 3/2. The former was a broadened doublet of doublets and the latter was an AB pattern with each peak further split into a broadened quartet. Two structures fit these spectral features entirely, but it is not possible to differentiate between these two at this moment.



It is worth noting that in both cases the carbon to which the SiF_2H group is attached is an asymmetric center. This will make the two fluorines in the SiF_2H group intrinsically nonequivalent, as is evident by the AB spectrum described above.

The yield of fraction (iii) was very low. The mass spectrum showed the highest mass peak m/e 264, corresponding to the molecular formula $C_{10}H_{12}Si_2F_4$. The proton decoupled ¹⁹F NMR spectrum showed an AA'BB'' pattern at 142.96 and 145.42 ppm, and two triplets at 136.49 and 137.53 ppm. The intensity ratio of the AA'BB' spectrum to the two triplets was roughly 8/1. Based on previous spectral assignments of similar compounds [1], the AA'BB' pattern is characteristic of an SiF₂SiF₂ unit involved in the rigid ring system 10, while two sets of triplets are characteristic of a free rotating chain structure 11.



All spectral data are summarized in Table 2.

Reaction with cycloheptatriene

The gas phase reaction of difluorosilylene with cycloheptatriene yielded polymeric materials and volatile products in an approximately relative ratio of 3/2. The

Fragment	m/e	Relative intensity (%)			
		12	13	12 + 13 + 14 + 15 ^a	
SiF ₂ ⁺	66	7		34	
$C_{7}H_{7}^{+}$	91	90	55	3	
$C_{7}H_{8}^{+}$	92	93	79	100	
$C_7 H_9^+$	93	14	7	31	
$C_7 H_8 SiF^+$	139	7	3		
Si ₂ F ₅ ⁺	151			35	
$C_7 H_8 SiF_2^+$	158	36	34	83	
$C_7 H_8 SiF_3^+$	177	15	4	6	
$C_7H_8Si_2F_4^+$	224	100	100	96	

MASS SPECTRAL DATA OF THE PRODUCTS FROM THE REACTION WITH CYCLOHEP-TATRIENE

^{*a*} 12:13:14:15 = 15:5:3:1.

volatile fraction contained mainly compound 12, in 15% yield on the basis of the quantity of cycloheptatriene used.



The characterization of 12 was based on the following spectral features: (i) the mass spectrum (Table 3) showed a molecular formula $C_7H_8Si_2F_4$ (m/e = 224); (ii) the proton decoupled ¹⁹F NMR spectrum showed four doublets of doublets of doublets with equal intensity, showing that the four fluorines are nonequivalent and that the molecule did not have a plane of symmetry; (iii) the ¹³C NMR spectrum showed four sp^2 carbons at 121.81, 131.42, 132.19 and 132.83 ppm, two sp^3 carbons with fluorine coupling at 28.00 and 33.63 ppm, and one saturated CH₂ carbon at 25.55 ppm; and (iv) the n-hexane solution of 12 showed a broad absorption with λ_{max} at 250 nm which is typical of a cyclic conjugated diene system. The only structure that fits all these spectral data is 12.

The mass spectral results of the reactions with cycloheptatriene are listed in Table 3 and NMR spectral results in Table 4.

The cocondensation reaction of difluorosilylene with cycloheptatriene yielded a reddish brown polymer. The volatile fraction (about 10% yield) contained mainly three compounds, 13, 12 and 14, with relative yields in a 20/2/1 ratio. A trace amount of compound 15 was also present in this fraction.



Compound	Chemical shift (δ (Coupling constant (Hz)			
	'H	¹⁹ F	¹³ C		
	$sp^2 5.6 \sim 6.1(br)$	54.98 (d,d,d)	sp ²	121.81(s)	$^{2}J(F-F)$ 32
	<i>sp</i> ³ 3.6(br)	55.17 (d,d,d)	-	131.42(s)	${}^{3}J(F-F)$ 14 (trans)
	2.0 ~ 2.5(br)	55.90 (d,d,d)		132.19(s)	$^{3}J(F-F) 7 (cis)$
		56.17 (d,d,d)		132.83(s)	
				33.63(c)	
13	$sp^2 5.8 \sim 6.1(br)$	54.24 (d,d,d)	sp ²	124.63(s)	$^{2}J(F-F)$ 21
	<i>sp</i> ³ 2.7(br)	55.83 (d,d,d)		126.80(s)	³ J(F-F) 14
	1.9 ~ 2.3(br)		sp ³ CH	31.00(c)	⁴ J(F−H) 7
			CH	I ₂ 24.49(s)	
14	sp ² 5.8 ~ 6.1(br)	56.22(t)			$^{2}J(F-H)$ 53
	sp ³ 2.7(br)	55.32(d,t)			$^{3}J(F-F) 6$
	SiH 4.7(t,t)				
15		54.93(d,d,d)			² J(F-F) 35
		55.51(d,d,d)			$^{3}J(F-F)$ 18
		56.26(d,d,d)			
		56.72(d,d,d)			
16		55.13(AB,d)			² J(F-H) 68
		55.27(br.s)			•

NMR PARAMETERS OF PRODUCTS FROM THE REACTION OF DIFLUOROSILYLENE WITH CYCLOHEPTATRIENE

Compound 13 was obtained in a pure crystalline form by fractional crystallization followed by vacuum sublimation. The mass spectrum suggested a molecular formula $C_7H_8Si_2F_4$. The ¹³C NMR spectrum showed two sp^2 carbons (δ 124.63 and 126.80 ppm), one saturated CH with fluorine couplings (δ 31.00 ppm) and one saturated CH₂ at δ 24.49 ppm. It is obvious from these data that the molecule has a plane of symmetry. The proton decoupled ¹⁹F NMR spectrum showed an AA'BB' pattern at 54.24 and 55.83 ppm respectively. The resonance at 55.83 ppm obviously showed a long range F–H coupling of 7 Hz which was best explained by the W shape of the F–Si–CH–C–H arrangement, therefore the resonance at 55.83 ppm must be assigned to F^A and F'^A.



Compound 14 showed in its mass spectrum the highest mass peak at m/e = 224, corresponding to the molecular formula $C_7H_8Si_2F_4$. Both ¹H and ¹⁹F NMR spectra showed the large geminal H-F coupling of 53 Hz, which was characteristic of the SiF₂H moiety. The proton decoupled ¹⁹F NMR spectrum showed a strongly coupled A_2B_2 pattern which suggested the existence of SiF₂SiF₂H. The most likely structure is 14.



SCHEME 1

Compound 15 was obtained only in a trace amount. However, the well separated ¹⁹F NMR spectrum definitely showed four broadened doublets of doublets at 54.93, 55.51, 56.26 and 56.72 ppm. This is the typical pattern of the bridge-head SiF_2SiF_2 unit; further, since the four fluorines are chemically nonequivalent, the molecule does not have a plane of symmetry. It seems quite certain that the only structure of this kind other than compound 12 is compound 15.

It is interesting to note that when an n-hexane solution of 13 was UV irradiated at -30° C for 12 h, it was converted to 12 almost quantitatively.

Compound 13 was not very stable in solution. It converts to 16 at room temperature even when kept in a vacuum-sealed tube.



Compound 16 was fully characterized by mass spectrometry and ¹⁹F NMR spectra. The mass spectrum suggested a molecular formula $C_7H_9Si_2F_5$ whereas the ¹⁹F NMR spectrum showed a singlet and a doublet at 55.13 and 55.27 ppm respectively for SiF₃ and SiF₂ (intensity ratio 3/2), with the latter showing a large geminal F-H coupling of 68 Hz.

In the reaction with cyclopentadiene it is believed that products 4-6 were formed via the generally accepted silirane intermediate [4] as is shown in Scheme 1.

Despite differences in the reaction conditions, it is interesting to note that the silirane intermediates intially formed in thermal reactions of dimethylsilylene and dichlorosilylene with cycloheptadiene rearrange to give silacyclohexadienes [12,13]. No product analogous to structure 6 was reported.

The formation of products 7-11 is best interpreted by the mechanism involving the \cdot SiF₂SiF₂ \cdot diradical as is shown in Scheme 2.

However, all these products may also be explained by the mechanism involving a silirane intermediate (Scheme 3).

In the gas phase reaction with cycloheptatriene, however, compound 12 was obtained. This is the first time that a compound involving the $-SiF_2SiF_2$ - unit is obtained as the major product in a gas phase reaction of diffuorosilylene [14]. Since







SCHEME 3

formation of oligomeric $(SiF_2)_n$ was not likely under the experimental conditions used in the gas phase reactions, the logical explanation for the formation of 12 is as shown in Scheme 4.



SCHEME 4



SCHEME 5

The formation of compounds 13–15 obtained in the cocondensation reaction is best explained by the mechanism involving the SiF_2SiF_2 diradical (Scheme 5).

The interpretation of the formation of 13–15 by the silirane mechanism is difficult (Scheme 6). Product 12 is a stable compound which did not lead to the formation of 13–15 under the experimental condition used. If the cocondensation reaction proceeded in a similar way to the reaction mechanism in the gas phase reaction (Scheme 4), one would expect that the major product in the cocondensation reaction was also 12. However, the major product in the cocondensation reaction was found to be 13 (85% relative yield), which could not be formed by sequential addition of SiF₂ unless very skeptical assumptions were made. One therefore tends to believe that at least in the case of the cycloheptatriene reaction, the SiF₂SiF₂ diradical mechanism is mainly responsible for the formation of 13–15. It seems to us that this is the first solid evidence which makes it possible to differentiate between the two mechanisms in the addition reactions of difluorosilylene.

Returning to the rationalization of the cyclopentadiene cocondensation reaction by the silirane mechanism (shown in Scheme 3), the formation of the diradical species leading to 7, 8, and 9 is doubtful given the present argument. It was



SCHEME 6



SCHEME 7

proposed in Scheme 3 that the diradical species was generated by C-Si bond cleavage of the disilacyclobutane intermediate. The experimental facts depicted in Scheme 7 strongly indicate that such strained disilacycles seem to favor the Si-Si cleavage much more than the C-Si cleavage [15].

Experimental

All reactions were carried out in a greaseless vacuum system similar to that used for previous studies of difluorosilylene chemistry described elsewhere [1,2]. All reagents were commercial products and used without further purification. Cyclopentadiene was freshly distilled from the mixture of its dimer before use.

The gas phase reactions were carried out in a previously evacuated 6 l bulb. Each run lasted for 25 min, approximately 10 times the half life of SiF_2 in the gas phase [14]. Reactions carried out under such conditions are believed to involve only monomeric SiF_2 .

Reaction with cyclopentadiene

When the products from the gas phase reaction with cyclopentadiene were subjected to prolonged pumping at -78° C, compound 6 was removed from the mixture as pure material. A sample containing only 4a and 4b was obtained by washing the polymers which coated the wall of the reaction bulb with chloroform.

The products of the cocondensation reaction with cyclopentadiene were separated into three fractions as is described in the text. The relative yields of the fractions were estimated by NMR integration to be 10/85/5.

Reaction with cycloheptatriene

The gas phase reaction with cycloheptatriene yielded mainly one product, 12, which was further purified by prolonged pumping at -10° C. The yield was approximately 15%.

The products of the cocondensation reaction with cycloheptatriene were further purified by pumping at -10° C. The crystals on the wall of the U-tube were subjected to vacuum sublimation which yielded compound 13. A reasonably pure sample of 14 was obtained by washing the crystals at -45° C with n-pentane (both

12 and 13 remained crystals at -45° C in n-pentane solution). All operations were carried out in a vacuum system fitted with a sintered glass filter.

Spectra

The mass spectra were obtained using a JMS 100 mass spectrometer. The ¹H, ¹⁹F, ¹³C, ²⁹Si NMR spectra were recorded on a JNM FX-100 spectrometer operating at 99.60, 93.70, 25.05 and 19.75 MHz, respectively. In all cases $CDCl_3$ was used as the solvent. Chemical shifts of ¹H, ¹³C and ²⁹Si were measured with TMS as internal reference, those of ¹⁹F were measured in ppm upfield from the internal reference, CCl_3F .

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